Properties of Spongy Structured BaTiO₃ Prepared by R.F. Magnetron Sputtering for Energy Harvester

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A sustainable energy-harvesting technique, which can transfer various forms of energy from the surrounding environment into electricity, could be an alternative to remedy the shortcomings of traditional battery technology [1-3]. New piezoelectric and triboelectric materials for energy harvesting are being widely researched to reduce their processing cost and complexity and to improve their energy conversion efficiency. In this study, $BaTiO_3$ films of various thickness were deposited on Ni foams by R.F. magnetron sputtering to study the piezoelectric and triboelectric properties of the porous spongy structure materials. Then piezoelectric nanogenerators (PENGs) were prepared with spongy structured BaTiO₃ and PDMS composite. The output performance exhibited a positive dependence on the thickness of the BaTiO₃ film, pushing load, and poling. The PENG output voltage and current were 4.4 V and 0.453 μ A at an applied stress of 120 N when poled with a 300 kV/cm electric field. The electrical properties of the fabricated PENG were stable even after 5,000 cycles of durability testing. The triboelectric nanogenerators (TENGs) were fabricated using spongy structured BaTiO₃ and various polymer films as dielectrics and operated in a vertical contact separation mode. The maximum peak to peak voltage and current of the composite filmbased triboelectric nanogenerator were 63.2 V and 6 µA, respectively. This study offers new insights into the design and fabrication of high output nanogenerators using spongy structured materials.



Figure 1. Illumination of red and blue LEDs at a load of 50 N

Figure 2. Output voltage generated at different speeds of vehicle.

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Supplementary information

Sputtering condition	
Substrate	Ni foam
Target	BaTiO ₃ (99.99%)
Target-substrate distance	100mm
Base pressure	5x10 ⁻⁶ torr
Working pressure	10mTorr
R.F. Power	150~210W
Deposition time	3h
Substrate Temperature	Room temperature

Table 1. Sputtering conditions for BaTiO₃ film preparation.



Figure 3. (a) SEM image of BaTiO₃ films deposited on Ni foam, (b) Enlarged cross-sectional image BaTiO₃ foams, (c) BaTiO₃ foams filled with PDMS and (d-f) EDS mapping images of (a).